

# STIC Search Report

## STIC Database Tracking Number 131654

**TO: Monica Lewis** 

Location: JEF-5A30 September 20, 2004

**AU 2822** 

Case Serial No.: 09/939,457

From: Jeff Harrison

**Location: STIC-EIC2800** 

**JEF-4B68** 

Phone: 22511

Email: harrison, jeff

### Search Notes

Examiner Lewis,

Re: Protruding electrodes, conductive film on top, insulating resin on side

Attached are edited results from patent and nonpatent literature.

If you'd like additional searching or explanation, let me know.

Respectfully, Jeff

Jeff Harrison

Team Leader, STIC-EIC2800

JEF-4B68, 571-272-2511





# STIC Search Report

## STIC Database Tracking Number 131654

**TO: Monica Lewis** 

Location: JEF-5A30 September 20, 2004

**AU 2822** 

Case Serial No.: 09/939,457

From: Jeff Harrison

**Location: STIC-EIC2800** 

**JEF-4B68** 

Phone: 22511

Email: harrison, jeff

### Search Notes

Examiner Lewis,

Re: Protruding electrodes, conductive film on top, insulating resin on side

Attached are edited results from patent and nonpatent literature.

If you'd like additional searching or explanation, let me know.

Respectfully, Jeff

Jeff Harrison Team Leader, STIC-EIC2800 JEF-4B68, 571-272-2511



```
FILE 'HCAPLUS, WPIX' ENTERED AT 15:20:06 ON 20 SEP 2004
L1
                  S
                        US20020048905/PN
L2
                SEL PLU=ON L1 1- IC RN :
L3
          97779
                   S
                        L2
L4
              2
                   S
                        L1 AND L3
                SEL PLU=ON L4 1- IC MC :
1.5
                                                13 TERMS
         410401
L6
                         (MEMBRAN##### OR FILM OR LAYER OR SUBLAYER
                OR COAT####) (3A) (ELECTRODE OR CONDUCT#######)
            397
L7
                         (PROTRU#### OR PROMINEN#### OR PROTUB#####)
                                                                      (5A) BUMP
              0
L8
                         (PROTRU#### OR PROMINEN#### OR PROTUB#####)
                                                                      (5A) BALLBUMP
L9
              1
                   S
                         (PROTRU#### OR PROMINEN#### OR PROTUB#####) (5A) GLOB
L10
           7543
                   S
                         (PROTRU#### OR PROMINEN#### OR PROTUB#####) (5A) CONTACT
L11
           1012
                   S
                         (PROTRU#### OR PROMINEN#### OR PROTUB#####) (5A) PAD
          10370
                        (PROTRU#### OR PROMINEN#### OR PROTUB#####) (5A) (ELECTRODE OR CONDUCT##### OR
                   S
L12
METAL############)
L13
             66
                   S
                        (PROTRU#### OR PROMINEN#### OR PROTUB#####) (5A) (CONDUCTIVE OR CONDUCTING OR
METAL######)(W) FILM
          29210
                   S
                         (NONCONDUCT####### OR NON CONDUCT OR NON ELECTRICALLY CONDUCT###### OR
INSULAT######## (3A) RESIN#####
L15
            193
                   S
                        RESIN####(5A)(SIDE## OR LATERAL###)(4A)(PROTRU#### OR PROMINEN#### OR
PROTUB####)
L16
                        {\tt L6} AND (L7 OR L8 OR L9 OR L10 OR L11 OR L12 OR L13)
           1543
                   S
L17
           1543
                   S
                        L6 AND (L7 OR L8 OR L9 OR L10 OR L11 OR L12)
L18
             34
                   S
                        L17 AND L13
L19
              1
                   S
                        L18 AND L14
L20
              1
                   S
                        L18 AND L15
L21
         101494
                   S
                        L5
L22
                        L18 AND L21
             - 8
                   S
L23
             34
                   S
                        L18 AND L6
L24
           1543
                   S
                        L6 AND (L7 OR L8 OR L9 OR L10 OR L11 OR L12 OR L13) AND (L14 OR L15 OR L16 OR
L17 OR L18)
L25
           1298
                        L24 AND (PROTRU#### OR PROMINEN#### OR PROTUB#####) (5A) (CONDUCT###### OR
ELECTRODE)
L26
            150
                   S
                        L25 AND RESIN
                        L26 AND (CONDUCT####### OR METAL###### OR FILM)(4A)(OBVERSE OR REVERSE OR
L27
             23
                   S
OTHER OR BOTTOM OR SIDE OR LOWER OR REAR OR BEHIND OR OTHER)
              3
                  S
                        L26 AND (CONDUCT####### OR METAL###### OR
                FILM) (4A) (BACK OR BACKSIDE)
              2
                   S
                        L26 AND (TWO OR THREE OR FOUR OR SEVERAL OR PAIR## OR COUPLE OR MATRIX#### OR
ARRAY##### OR LINE OR ROW OR COLUMN) (2A) BUMP
L30
         15781 S
                        (PROTRU#### OR PROMINEN#### OR PROTUB#####) (3A) (TWO OR THREE OR FOUR OR SEVERAL
OR PAIR## OR COUPLE OR MATRIX#### OR ARRAY##### OR LINE OR ROW OR COLUMN)
             7
                  S
                        L6 AND L7 AND (RESIN#### OR EPOX#### OR NOVOLAK OR
POTTING) (4A) (NONCONDUCT###### OR NON CONDUCT### OR INSULAT####)
L32
             9
                   S
                        L26 AND L30
L33
             73
                   S
                        L9 OR (L18 OR L19 OR L20) OR L22 OR L23 OR (L27 OR L28 OR L29) OR (L31 OR L32)
         101502
L34
                   S
                        L5
                        L34 AND L33
L35
             20
                   S
              9
L36
                   S
                        L33 AND INTERCONNECT?
L37
              7
                   S
                        L33 AND BUMP AND RESIN AND FILM
L38
             34
                   S
                        L9 OR L19 OR L20 OR L22 OR L28 OR L29 OR L31 OR L32 OR L36 OR L37
                        L27 AND L35
L39
              9
                   S
L40
             36
                   S
                        L38 OR L39
L41
             36
                   S
                        L40 NOT L4
     FILE 'JAPIO, INSPEC, EUROPATFULL, PCTFULL' ENTERED AT 15:48:11 ON 20 SEP 2004
                        (PROTRU#### OR PROMINEN#### OR PROTUB#####) (4A) (BUMP OR CONTACT OR
L42
           2344
                   S
ELECTRODE) /TI, AB, CLM, CT, ST
                        (PROTRU#### OR PROMINEN#### OR PROTUB#####) (4A) (BUMP OR CONTACT OR
            408
                   S
ELECTRODE) / AB
                        (L42 OR L43) AND (FILM OR TOP) (3W) (PROTRU#### OR PROMINEN#### OR PROTUB##### OR
L44
             18
                   S
BUMP) /TI, AB
                        L44 AND (RESIN#### OR EPOX##### OR POTTING OR NOVOLAK) (4A) (CONTACT#### OR SIDE
              0
                   S
L45
OR LATERAL###) (3A) (BUMP OR ELECTRODE OR PROTRU#### OR PROMINEN#### OR PROTUB#####)/TI,AB
L46
             9
                   s
                        L44 AND (FILM OR LAYER OR MEMBRAN####) (2A) (CONDUCT### OR ELECTRODE)
              1
                   S
                        L44 AND INTERCONNECT#####/TI, AB, ST, CT, CLM
L47
L48
              3
                   S
                        L44 AND (RESIN#### OR EPOX##### OR POTTING OR NOVOLAK)/TI,AB,CLM,ST,CT
L49
             10
                   S
                        (L46 OR L47 OR L48)
```

8 .

ì

· Militaro		•
SEARCH REQUEST FORM Scientific an Rev. 3/15/2004 This is an experimental format Please give:	131654  nd Technical Information Center - EIC suggestions or comments to Jeff Harrison, JEF-4868, 27:	22800 2:2311
Date 92 0 Serial # 091939,45	Priority Application Date	
Your Name W. \ S	( Management of	J 107 850 \$
Tour Name	Examiner #	
AU 200 Phone 2002-1	(3) Room 5430	
In what format would you like your results? Paper is the	e default. PAPER DISK EN	MAIL
If submitting more than one search, please prioritize	te in order of need.  Week belief	æ.
The EIC searcher normally will contact you before b with a searcher for an interactive search, please not	peginning a prior art search. If you would like tify one of the searchers.	ce to sit
Where have you searched so far on this case?		
Circle: USPT DWPI EPO A	Abs JPO Abs IBM TDB	
Other:	09-03-14 4 9:18 ;	•
What relevant art have you found so far? Please Information Disclosure Statements.	e attach pertinent citations or	
What types of references would you like? Please Primary Refs Nonpatent Literature Secondary Refs Foreign Patents  Teaching Refs  What is the topic, such as the novelty, motivation, desired focus of this search? Please include the cregistry numbers, definitions, structures, strategies topic. Please attach a copy of the abstract and pertagging the secondary Refs  Provided Teaching Refs  What is the topic, such as the novelty, motivation, desired focus of this search? Please include the cregistry numbers, definitions, structures, strategies topic. Please attach a copy of the abstract and pertagging the company of the provided the cregistry numbers, definitions, structures, strategies topic. Please attach a copy of the abstract and pertagging the company of the com	Other  , utility, or other specific facets defining concepts, synonyms, keywords, acronyms, and anything else that helps to describe	
<u> </u>	<u> </u>	
and the second s	A CONTRACTOR OF THE PROPERTY O	
•		
Staff Use Only 114 C . Type of Search	Vendors .	
Starf Use Only Searcher:  Structure (#)	STN	
Searcher Phone: 275   Bibliographic	Dialog	
Searcher Location: STIC-EIC2800. JEF-4B68 Litigation	Questel/Orbit	
Date Searcher Picked Up: G - CO / Fulltext X	Lexis-Nexis	
Date Completed:	WWW/Internet	
Searcher Prep/Rev Time: Other	Other	

Online Time:

```
L41 ANSWER 5 OF 36 HCAPLUS COPYRIGHT ACS on STN
   1995:708435 HCAPLUS Full-text
DN
   123:99795
ED Entered STN: 29 Jul 1995
TI Electric conductor - insulator resin composites and
    circuit boards
IN Azuma, Kazumi; Maeda, Masako
PA
    Nitto Denko Corp, Japan
    Jpn. Kokai Tokkyo Koho, 9 pp.
SO
    CODEN: JKXXAF
DT
    Patent
LA
    Japanese
    ICM H05K001-02
IC
    ICS H05K001-03; H05K003-46
ICA H05K001-11
   76-2 (Electric Phenomena)
FAN.CNT 1
    PATENT NO.
                     KIND DATE APPLICATION NO.
                                                              DATE
PI JP 07030212
                      ----
                             -----
                                         -----
                                                               -----
                              19950131
                                         JP 1993-169342
                       A2
                                                              19930708
PRAI JP 1993-169342
                              19930708
CLASS
               CLASS PATENT FAMILY CLASSIFICATION CODES
 PATENT NO.
                                                                                     ______
               ICM
 JP 07030212
                      H05K001-02
                ICS
                      H05K001-03; H05K003-46
                ICA H05K001-11
AB
     Through holes are formed in insulator resin films (e.g., polyimide) covered with elec. conductive
     films (e.g., Cu foils), and metals are protruding bump-like from the holes. Plastic films may be
     formed on the resin films on the opposite side of the elec. conductive films. The elec.
     conductive films may be patterned into elec. circuits, or the composite films are laminated, and
     the interlayer circuits are connected across the holes.
ST
    elec conductor insulator composite circuit board; copper polyimide
    composite circuit board
IT
    Polyimides, uses
    RL: DEV (Device component use); USES (Uses)
       (elec. conductor - insulator resin composites and
       circuit boards)
IT
    Electric circuits
       (printed, boards, elec. conductor - insulator resin
       composites for)
    7440-50-8, Copper, uses
IT
    RL: DEV (Device component use); USES (Uses)
       (elec. conductor - insulator resin composites and
       circuit boards)
L41 ANSWER 6 OF 36 HCAPLUS COPYRIGHT ACS on STN
AΝ
    1993:615340 HCAPLUS Full-text
DN
    119:215340
    Entered STN: 13 Nov 1993
ED
TI
    Anisotropic electrically conductive film, and method
    for connecting electronic devices by using such film
    Kobayashi, Hiroshi; Yoshida, Yoshihiro; Kozuka, Takeshi; Iwabuchi,
ΤN
    Toshiaki
PA
    Ricoh Kk, Japan
    Jpn. Kokai Tokkyo Koho, 5 pp.
SO
    CODEN: JKXXAF
DT
    Patent
LA
    Japanese
IC
    ICM H01R011-01
    ICS C08K003-08; C08L101-00; H01B005-16; H05K003-32
CC
    76-2 (Electric Phenomena)
FAN.CNT 1
```

APPLICATION NO.

DATE

KIND DATE

PATENT NO.

```
A2
                               19930226
                                           JP 1991-201000
                                                                 19910812
     JP 05047428
                                            JP 1991-201000
                                                                   19910812
CLASS
 PATENT NO.
               CLASS PATENT FAMILY CLASSIFICATION CODES
 -----
                     H01R011-01
                ICM
 JP 05047428
                ICS
                       C08K003-08; C08L101-00; H01B005-16; H05K003-32
     In a porous insulating film (especially, anodized Al film) having a plurality of through openings
AB
     containing electrodes, the electrodes protrude from the film surface and consist of a metal matrix
     having high oxidation resistance (e.g., Au and Ni) and dispersed hard particles (e.g., A203 and
     SiC) having hardness higher than that of the contacts of elec. devices to be connected. Elec.
     devices are connected by placing the film between them and applying ultrasonic wave. The hard
     particles destroy the oxidation film present on the contacts of the elec. devices thus providing
     for reliable elec. contact.
     anisotropic elec conductive film; gold alumina
ST
     composite elec contact; connecting elec device film ultrasonic wave
IT
        (composite, of gold or nickel matrix with alumina or silicon carbide
        hard particles, in anisotropic elec. conductive film
        for connecting elec. devices)
     Sound and Ultrasound
IT
        (in connecting elec. devices by using anisotropic elec.
        conductive film)
TΤ
        (elec. conductive, anisotropic, with protruding
        composite contacts for connecting elec. devices)
ΙT
     Electric conductors
        (interconnections, with anisotropic elec. conductive
        film with protruding composite contacts
        for, for elec. apparatus)
L41 ANSWER 14 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN
AN
     2002-237016 [29] WPIX Full-text
     2001-366493 [38]; 2001-488377 [53]; 2002-089225 [12]; 2002-341542 [38]; 2002-488845 [52]; 2002-626277 [67]; 2002-749686 [81]
                      DNC C2002-071686
DNN N2002-182324
     Semiconductor device for mounting on substrate, includes chip provided
TI
     with bonding pads, in which conductive bodies are transferred to pad
     mounting surface to establish electrical connection of bonding pads and
     solder points.
DC
     L03 U11
IN
     CHEN, I
     (CHEN-I) CHEN I
PΑ
CYC 1
PΙ
     US 6333561
                   B1 20011225 (200229) *
                                            9 H01L023-48
ADT US 6333561 B1 US 2000-564989 20000505
PRAI TW 2000-100578
                         20000121
     ICM H01L023-48
     ICS H01L023-40; H01L023-52
     US 6333561 B UPAB: 20030820
AB
     NOVELTY - Semiconductor device comprises a semiconductor chip having a pad-mounting surface
     provided with bonding pads. Conductive bodies are transferred from a conductor-forming mold to the
     pad mounting surface, to establish the required electrical connection among the bonding pads and
     the solder points.
          DETAILED DESCRIPTION - A semiconductor device for mounting on a substrate (9) having a chip-
     mounting region with solder points, comprises a semiconductor chip. The chip has a pad-mounting
     surface (10) provided with bonding pads (11) at locations that are offset from locations of
     corresponding solder points on the chip-mounting region. Conductive bodies have extension portion
     which is electrically connected to respective bonding pads. The bodies have an electrical
     connection portion which is formed on an end of the extension portion. The conductive bodies are
```

formed by providing a **conductor**-forming mold having a **side** formed with **conductor**-receiving cavities. The cavities include a first cavity part which is disposed in the conductor-forming

đ

mold. The conductor-receiving cavities are filled with a conductive metal paste (91) to form the conductive bodies. The extension portions of the conductive bodies are disposed in the first cavity parts of the conductor-receiving cavities. The electrical connection portions of the conductive bodies are disposed in the second cavity parts of the conductor-receiving cavities. The conductive bodies are transferred from the conductor-forming mold to the pad-mounting surface of the semiconductor chip, through a transfer printing unit.

USE - For mounting on a substrate.

ADVANTAGE - Prevents the occurrence of short-circuiting due to the relatively short distance between bonding pads.

DESCRIPTION OF DRAWING(S) - The figures show a sectional view and a fragmentary schematic view of the semiconductor device.

insulator barriers 8

substrate 9

pad-mounting surface 10

bonding pads 11

conductive metal paste 91

Dwg.9,11/11

TECH US 6333561 B1 UPTX: 20020508

TECHNOLOGY FOCUS - ELECTRONICS - Preferred Component: Insulator barriers (8) are formed on the pad-mounting surface, between an adjacent pair of the bonding pads. Conductive balls are disposed on the electrical connection portion of the conductive bodies. A protective layer made of an insulator material, is formed on the pad-mounting surface of the chip. The conductive balls protrude through the protective layer.

TECHNOLOGY FOCUS - POLYMERS - Preferred Material: The insulator barriers and the protective layer are formed from a resin material.

TECHNOLOGY FOCUS - INORGANIC CHEMISTRY - Preferred Material: The conductive balls are copper balls electroplated with a conductive metal material. The conductive metal paste contains silver, gold, copper, iron, aluminum, tin, and lead.

```
L41 ANSWER 15 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN
```

ΑN 2002-165697 [22] WPIX Full-text

2002-084295 [12]; 2002-488559 [52]; 2003-864465 [80] CR

DNN N2002-126522

Slim-line circuit board for portable devices e.g. mobile telephones, uses ΤI epoxy resin to support conductive tracks.

DC: T01 U11 W01

JP 2000-194094

KOBAYASHI, Y; MAEHARA, E; MASHIMO, S; OKAWA, K; SAKAMOTO, J; SAKAMOTO, N; TN TAKAHASHI, K

(SAOL) SANYO ELECTRIC CO LTD; (KOBA-I) KOBAYASHI Y; (MAEH-I) MAEHARA E; PA (MASH-I) MASHIMO S; (OKAW-I) OKAWA K; (SAKA-I) SAKAMOTO J; (SAKA-I) SAKAMOTO N; (TAKA-I) TAKAHASHI K

CYC 30

ΡI EP 1122778 A2 20010808 (200222) \* EN 32 H01L023-31

> R: AL AT BE CH CY DE DK ES FI FR GB GR IE IT LI LT LU LV MC MK NL PT RO SE ST

JP 2001217338 A 20010810 (200222) 15 H01L023-12 A 20010810 (200222) JP 2001217353 15 H01L023-28 A 20010810 (200222) 1.5 H01L023-50 JP 2001217372 A 20010817 (200222) 18 H01L025-04 JP 2001223317 JP 2001223318 A 20010817 (200222) 17 H01L025-04 JP 2001223320 A 20010817 (200222) 19 H01L025-04 KR 2001078000 A 20010820 (200222) H05K001-02 A 20020403 (200247) H05K001-00 CN 1343086 US 6548328 B1 20030415 (200329) H01L021-44 H01L029-74 US 2003151135 Al 20030814 (200355) H01L023-48 US 2003160317 A1 20030828 (200357) TW 535462 A 20030601 (200374) H05K001-00 20000131; PRAI JP 2000-32454 20000209; JP 2000-22646 JP 2000-24047 20000201; JP 2000-32417 20000209; 20000131; JP 2000-194093 20000209

```
ICM H01L021-44; H01L023-12; H01L023-28; H01L023-31; H01L023-48;
IC
         H01L023-50; H01L025-04; H01L029-74; H05K001-00; H05K001-02
     ICS H01L021-301; H01L021-48; H01L021-50; H01L021-56; H01L025-00;
         H01L025-10; H01L025-11; H01L025-18; H01L031-111; H05K001-18;
         H05K003-30
AΒ
          1122778 A UPAB: 20031211
     NOVELTY - The slim-line circuit board has semiconductor components mounted on pressed metal i.e.
     copper, conductive paths that are supported in a glass epoxy insulating resin substrate. The paths
     are conductively coated with gold, silver or nickel. External connections are made via protruding
     conductive elements on the circuit back face.
          DETAILED DESCRIPTION - An INDEPENDENT CLAIM is made for a method of manufacturing a circuit
     board.
          USE - Slim-line circuit boards for use in portable equipment such as mobile telephones or
     laptop computers.
          ADVANTAGE - The manufactured circuit boards are lighter in weight and thinner in profile.
     Dwg.0/29
TECH EP 1122778 A2 UPTX: 20020409
     TECHNOLOGY FOCUS - POLYMERS - The conductive tracks are supported in a
     glass epoxy resin substrate.
L41 ANSWER 16 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN
     2002-121269 [16] WPIX Full-text
AN
                       DNC C2002-037021
DNN N2002-090951
     Semiconductor device has semiconductor substrate including signal pads and
TI
     ground pads, insulating film, conductive metal
     film, and first interconnection lines.
     A85 L03 U11
DC
     FUKASAWA, N; IKUMO, M; KAWAHARA, T; NAGASHIGE, K
IN
     (FUIT) FUJITSU LTD; (FUKA-I) FUKASAWA N; (IKUM-I) IKUMO M; (KAWA-I)
PΑ
     KAWAHARA T; (NAGA-I) NAGASHIGE K
CYC
     US 2001023981 A1 20010927 (200216)*
                                              23
                                                     H01L021-44
PΙ
                                                12
                                                     H01L021-60
                                                                     <--
     JP 2001267350 A 20010928 (200216)
                                                     H01L023-12
     KR 2001089139 A 20010929 (200220)
                                                     H01L023-52
     US 6437432
                    B1 20020820 (200257)
                                                                                                 (In
                                                     H01L021-768
     TW 484204
                    A 20020421 (200314)
    US 2001023981 A1 US 2000-745742 20001226; JP 2001267350 A JP 2000-78935
     20000321; KR 2001089139 A KR 2001-3171 20010119; US 6437432 B1 US
     2000-745742 20001226; TW 484204 A TW 2001-100287 20010105
PRAI JP 2000-78935
                         20000321
     ICM H01L021-44; H01L021-60; H01L021-768; H01L023-12;
          H01L023-52
         H01L021-3205; H01L021-48; H01L021-50; H01L021-56;
     ICS
          H01L023-02
     US2001023981 A UPAB: 20020308
AB
     NOVELTY - A semiconductor device comprises a semiconductor substrate including signal pads and
     ground pads; an insulating film formed on the substrate; a conductive metal film formed on the
     insulating film and electrically connected to the ground pads; and first interconnection lines
     electrically connected to the signal pads and insulated from the conductive metal film.
           DETAILED DESCRIPTION - A semiconductor device comprises a semiconductor substrate (21)
     including signal pads (25) and ground pads (26); an insulating film formed on the substrate; a
     conductive metal film (29A) formed on the insulating film and electrically connected to the ground
     pads; and first interconnection lines (28A) electrically connected to the signal pads and
     insulated from the conductive metal film. The conductive metal film is formed over a region
     including the first interconnection lines in a plan view of the device.
           An INDEPENDENT CLAIM is also included for a method of producing the semiconductive device,
     comprising:
           (a) forming a first insulating film on the substrate including the signal and ground pads
     except for positions where the signal and ground pads are formed;
```

(d) forming the interconnection lines on the second insulating film;(e) forming protrusion electrodes each having a predetermined height on the interconnection lines; and

(c) forming a second insulating film over the conductive metal film;

where the signal pads are formed;

(b) forming the conductive metal film on the first insulating film except for the positions

(f) providing resin sealing on the first and second insulating films (30, 31), the conductive metal film, the interconnection lines, and sides of the protrusion electrodes.

USE - As a semiconductor device.

ADVANTAGE - The inventive device has improved electrical characteristic to become a fast semiconductor device employing a high frequency. Since, the **conductive** metal **film** is electrically insulated from the **interconnection** lines, the **conductive** metal **film** does not cause a short circuit between the **interconnection** lines and the ground.

DESCRIPTION OF DRAWING(S) - The figure shows a sectional view of a semiconductor device. Substrate 21

First protrusion electrodes 22

Second protrusion electrodes 23 Sealing resin 24

Signal pads 25

Ground pads 26

First interconnection lines 28A

Conductive metal film 29A

First and second insulating films 30, 31 Dwg.3/14

TECH US 2001023981 A1UPTX: 20020308

TECHNOLOGY FOCUS - ELECTRONICS - Preferred Component: The device includes

first protrusion electrodes (22) electrically

connected to the first interconnection lines; second

protrusion electrodes (23) electrically connected to and

formed directly on the conductive metal film; and a

sealing resin (24) sealing the signal and ground pads, the

insulating film, the conductive metal film,

the first interconnection lines, and side of the first and

second protrusion electrodes. The ground pads

are connected directly to the conductive metal film.

Protective metal films are formed on the signal or ground pads. The first

interconnection lines are formed above the conductive

metal film. Second interconnection lines electrically

connect the ground pads and the second protrusion

electrodes, and are included in the region. They are formed above

the conductive metal film.

```
L41 ANSWER 17 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN
     2001-610477 [70]
                       WPIX Full-text
AN
                       DNC C2001-182282
DNN N2001-455666
     Capacitor electrode used in semiconductor devices such as DRAM bit cells
ΤI
     has dielectric post protruding dielectric film, a
     first conductive film on the dielectric post, and a
     second conductive film under the dielectric post.
     L03 U12 U13 U14 V01
DC
     JIANG, B; MELNICK, B M; ROBERTS, D R; WHITE, B E
ΤN
     (MOTI) MOTOROLA INC
PΑ
CYC
                                               12 H01L027-108
PΙ
     US 6274899
                    B1 20010814 (200170)*
ADT US 6274899 B1 US 2000-574952 20000519
PRAI US 2000-574952
                         20000519
     ICM H01L027-108
IC
     ICS H01G004-10; H01L027-112; H01L029-92
AB
          6274899 B UPAB: 20011129
     NOVELTY - Capacitor electrode comprises: a dielectric film having a recess overlying a
     semiconductor device, a dielectric post protruding from the dielectric film and having an outer
     peripheral boundary defined by side walls, and a top surface; a first conductive film on the
     dielectric post, at least along its sidewalls; and a second conductive film under the dielectric
     post.
          DETAILED DESCRIPTION - Preferred Features: The second conductive film lines the recess, and
     portions of the dielectric post, extend into the recess. The first and second conductive films are
     electrically connected together and define portions of a capacitor electrode. At least one of the
     conductive films includes a material selected from iridium, platinum, palladium, ruthenium,
     rhenium, rhodium and osmium.
          A third conductive film can be formed over the top surface of the dielectric post, the first,
     second and third conductive films being electrically interconnected and defining portions of the
     capacitor electrode.
          The portions of the dielectric post extending into the recess comprise an oxygen barrier.
          An oxygen barrier including a material selected from iridium and ruthenium is disposed within
          The oxygen barrier comprises:
           (i) a conductive layer that lines the recess, and which is selected from iridium oxide,
     ruthenium oxide, titanium nitride, titanium aluminum nitride, titanium silicon nitride, tantalum
     nitride, tantalum aluminum nitride, tantalum silicon nitride, metal nitrides, metal borides and
     metal carbides; and
           (ii) a dielectric material.
          An INDEPENDENT CLAIM is given for an alternative embodiment of a capacitor electrode.
          USE - Manufacture of semiconductor devices, especially dynamic random access memory (DRAM)
     bit cells.
          ADVANTAGE - Thinner conductive materials can be used to form electrodes having larger overall
     surface area and are intrinsically easier to etch. The etch to define the capacitor electrode does
     not require patterning; instead, feature size and spacing is determined by patterning and etching
     of the dielectric posts. The cost of forming the electrode is reduced.
          DESCRIPTION OF DRAWING(S) - The drawing shows an illustration of a cross-sectional view of a
     capacitor structure according to an embodiment of the invention.
          Semiconductor device substrate 10
          Field isolation regions 102
          Doped regions 104
          Gate dielectric film 106
          Gate electrode 108
          Dielectric film 110
          Contact opening 112
          Conductive fill material 116
     Transistor 118
            Conductive films 1004,1008, 1102
          Bottom electrode of capacitor 1200 Dwg.12/18
```

```
Solar battery has insulating substrate with hemispherical protrusions on
    which two electrode layers sandwiching P and N type
     semiconductor layers are formed.
DC.
     FUKUI, A; KIMOTO, K
IN
     (MIHI) MITSUI HIGH TEC KK; (MIHI) MITSUI HIGH TEC INC
PΑ
CYC 2
     JP 2001156316 A 20010608 (200148)*
                                                      H01L031-04
PΙ
                   B1 20020716 (200248)
                                                      H01L031-042
    US 6420644
     JP 2001156316 A JP 1999-336789 19991126; US 6420644 B1 US 2000-723042
ADT
     20001127
PRAI JP 1999-336789
                         19991126
     ICM H01L031-04; H01L031-042
IC
     ICS H01L031-048
     JP2001156316 A UPAB: 20010829
AB
     NOVELTY - An insulating substrate (1) has hemispherical protrusions on its surface. An electrode
     layer (10), P and N type amorphous silicon layers (11,12), and another electrode layer (13)
     consisting of transparent material, are formed sequentially on the substrate.
          DETAILED DESCRIPTION - An INDEPENDENT CLAIM is also included for solar battery manufacturing
     method.
          USE - Solar battery.
          ADVANTAGE - Uses heat resistant glass or resin as substrate so that manufacture of solar
     battery becomes simple. Secures large element area and stable output characteristics.
          DESCRIPTION OF DRAWING(S) - The figure shows the sectional view of solar battery.
          Insulating substrate 1
            Electrode layers 10,13
          P and N type amorphous silicon layers 11,12 Dwg.2/10
L41 ANSWER 19 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN
    2000-278886 [24] WPIX Full-text
ΑN
    1998-548150 [47]; 1999-606634 [52]; 2000-278885 [24]; 2000-669049 [65]
CR
DNN N2000-210229
     Variable resistor for high voltage applications, has connection terminal
     with cylindrical portion whose edge part protrudes from insulated
     resin layer, by connecting conducting rubber
     at backside of circuit board.
DC
    V01
     (HOKU-N) HOKURIKU DENKI KOGYO KK
PΑ
CYC
                                                 7
                                                     H01C013-00
     JP 2000077217 A 20000314 (200024)*
ΡI
                   B2 20010711 (200140)
                                                7
                                                    H01C013-00
     JP 3187395
     JP 2000077217 A Div ex JP 1998-62758 19860528, JP 1999-204651 19860528; JP
ADT
     3187395 B2 Div ex JP 1998-62758 19860528, JP 1999-204651 19860528
    JP 3187395 B2 Previous Publ. JP 2000077217
FDT
                         19860528; JP 1999-204651
                                                       19860528
PRAI JP 1998-62758
     ICM H01C013-00
     ICS H01C001-02; H01C001-14
     JP2000077217 A UPAB: 20010719
AB
     NOVELTY - Opening in insulated case (1) is filled with insulated resin, so that an insulated resin
     layer (6) is formed on backside of circuit board (5). Edge of cylindrical portion (7b) of a
     connection terminal (7) protrudes from the insulated resin layer by connecting cylindrical
     conducting rubber (7c) at backside of circuit board. A lead wire support (4) supports lead wire
     for focus output inside the case.
          DETAILED DESCRIPTION - A sluder is provided between the insulated case (1) and the surface of
     circuit board (5). The circuit board having a resistor circuit pattern with variable resistance
     body is contained inside the insulated case.
          USE - The variable resistor combined with fly back transformer is used for high voltage
     application such as in television receiver.
          ADVANTAGE - The connection of variable resistor with fly back transformer can be performed
     simply and reliably, without connecting lead wire during final processing.
          DESCRIPTION OF DRAWING(S) - The figure shows fragmentary sectional view of variable resistor.
     Insulated case 1
          Lead wire support 4
     Circuit board 5
            Insulated resin layer 6
          Connection terminal 7
```

Cylindrical portion 7b Cylindrical conducting rubber 7c Dwg.1/10

ICM G02F001-1345 ICS H05K003-36

```
L41 ANSWER 20 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN
     2000-278885 [24] WPIX Full-text
ΑN
     1998-548150 [47]; 1999-606634 [52]; 2000-278886 [24]; 2000-669049 [65]
CR
DNN N2000-210228
     High voltage variable resistor for use in television, has terminal
     provided at back side of circuit board, so that conducting
     rubber protruding from resin layer is inserted into
     cylindrical.
DC
     V01 V04
     (HOKU-N) HOKURIKU DENKI KOGYO KK
PΑ
CYC 1
                                                7
ΡI
     JP 2000077216 A 20000314 (200024)*
                                                     H01C013-00
     JP 3187394 B2 20010711 (200140) 7
                                                   H01C013-00
ADT JP 2000077216 A Div ex JP 1998-62758 19860528, JP 1999-204646 19860528; JP
     3187394 B2 Div ex JP 1998-62758 19860528, JP 1999-204646 19860528
FDT JP 3187394 B2 Previous Publ. JP 2000077216
                         19860528; JP 1999-204646 19860528
PRAI JP 1998-62758
     ICM H01C013-00
IC
     ICS H01C001-02; H01C001-14; H01R011-01
AB
     JP2000077216 A UPAB: 20010719
     NOVELTY - A circuit board (5) with variable resistor circuit pattern, is provided inside an
     insulated case (1) having aperture at one end. The opening is filled with resin and an insulated
     resin layer (6) is provided to back side of circuit board. A connection terminal (7) at back side
     of circuit board has cylindrical portion (7b) to insert cylindrical conducting rubber (7c)
     protruded from the resin layer.
          DETAILED DESCRIPTION - The terminal is provided such that the circular end of rubber is
     exposed from the edge of the cylindrical portion. A slider is provided between the insulated case
     and circuit board.
          USE - For flyback transformer used in television .
          ADVANTAGE - Since the conducting rubber is inserted into the cylindrical portion, need for
     fixing the conductor to flyback transformer side is avoided. The conducting rubber prevents
     reduction of dielectric strength.
          DESCRIPTION OF DRAWING(S) - The figure shows the sectional view of high voltage variable
     resistor.
     Insulated case 1
     Circuit board 5
            Insulated resin layer 6
          Connection terminal 7
          Cylindrical portion 7b
          Cylindrical conducting rubber 7c Dwg.1/10
L41 ANSWER 21 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN
AN
     2000-226863 [20] WPIX Full-text
DNN N2000-170097
                       DNC C2000-069514
     Multilayered anisotropic conductivity film for
     connecting LCDs and flexible board - has insulating layer and particle
     layer dispersed with electrically conductive particles
     and has thickness of particle layer below projection point of ball
     bump.
DC
     A85 L03 P81 U14 V04
PA
    (MATU) MATSUSHITA DENKI SANGYO KK
CYC 1
                                                7
                                                     G02F001-1345
     JP 11326935
                    A 19991126 (200020)*
                                               6
                                                     G02F001-1345
     JP 3438583
                    B2 20030818 (200356)
ADT JP 11326935 A JP 1998-125709 19980508; JP 3438583 B2 JP 1998-125709
     19980508
FDT
     JP 3438583 B2 Previous Publ. JP 11326935
                       19980508
PRAI JP 1998-125709
```

AB JP 11326935 A UPAB: 20000502

NOVELTY - The particle layer (4) is distributed with electrically conductive particles (5). The anisotropic **conductivity film** (20) is formed by laminating insulating layer (3) and particle layer (4), mechanically. The thickness of the particle layer (4) is made below the projection of the point of the ball **bump** (2).

DETAILED DESCRIPTION - Ball bump (2) with a two step protrusion is formed on semiconductor chip (1). The insulating layer (3) is formed by an insulating and adhesive resin . An INDEPENDENT CLAIM is also included for connecting method of LCD and flexible board.

USE - For connecting LCDs with flexible board. Also for connecting semiconductor chip onto printed wiring board.

ADVANTAGE - The junction reliability is increased using simple technique.

DESCRIPTION OF DRAWING - The figure shows the sectional view of the multilayered anisotropic conductivity film. (1) Semiconductor chip; (2) Ball bump; (3) Insulating layer; (4) Particle layer; (5) Electrically conductive particle; (20) Anisotropic conductive film. Dwg.1/8

FS CPI EPI GMPI

FA AB; GI

MC CPI: A12-E07A; A12-E07C; A12-L03B; L03-G05A; L03-H04E; L04-C10; L04-C17

EPI: U14-K01A4B; V04-R04

#### L41 ANSWER 22 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN

AN 1999-625309 [54] WPIX <u>Full-text</u>
DNN N1999-462050 DNC C1999-182637

TI Chip mounting method for manufacturing semiconductor device - involves connecting electrically metal bump and electrode of chip and circuit board respectively by thermocompression bonding process using alloy layer.

DC A85 L03 U11

PA (MATE) MATSUSHITA ELECTRONICS CORP

CYC 1

PI JP 11274241 A 19991008 (199954)\* 12 H01L021-60

ADT JP 11274241 A JP 1998-79632 19980326

PRAI JP 1998-79632 19980326

IC ICM H01L021-60

AB JP 11274241 A UPAB: 20000105

NOVELTY - A bonding tool (30) **couples** a metal **bump** (27) of a semiconductor chip (10), to an electrode (41) of a circuit board (40) by thermocompression bonding process through an alloy layer. A **resin** layer (24B) that surrounds the metal bump is stiffened, thereby promoting coupling between the chip and the circuit board.

DETAILED DESCRIPTION - Protruding electrodes (23) are formed on each of the pads (21) of a wafer (20). A resin layer (24A) surmounts the substrates including the electrodes (23). The resin layer is then polished along with the electrode, so that surface of the electrode is in agreement with that of the resin layer (24b). Multiple chips (10) are produced by slicing the substrate suitably.

USE - For manufacturing semiconductor devices.

ADVANTAGE - Since chip is mounted on circuit board, bare chip mounting process becomes possible. Therefore manufacturing cost is reduced. Electrical connection between electrode and bump and between circuit board and chip are performed simultaneously using alloy layer and resin layer. Thus product yield is improved.

DESCRIPTION OF DRAWING - The figure shows sectional view of process involved in manufacturing of semiconductor device. (10) Multiple chips; (20) Wafer; (21) Pads; (23,41) Electrodes; (24A,24B,24b) Resin layers; (30) Bonding tool; (40) Circuit board. Dwg.1/12

#### L41 ANSWER 23 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN

AN 1999-173068 [15] WPIX Full-text

DNN N1999-127087

TI Semiconductor device mounting method on wiring board - involves filling gap between semiconductor device and wiring board using combination of electroconductive glue and resin layer or anisotropic electrically conductive sheet.

DC U11 V04

IN BESSHO, Y; HASE, N; ITAGAKI, M; NAKAMURA, Y; TAKEZAWA, H; YUHAKU, S

PA (MATU) MATSUSHITA DENKI SANGYO KK; (MATU) MATSUSHITA ELECTRIC IND CO LTD

CYC 2
PI JP 11026631 A 19990129 (199915) \* 6 H01L023-12
US 6207550 B1 20010327 (200119) H01L021-44

ADT JP 11026631 A JP 1997-176844 19970702; US 6207550 B1 US 1998-107319
19980630

PRAI JP 1997-176844 19970702
IC ICM H01L021-44; H01L023-12
ICS H05K001-18

NOVELTY - A multilayered wiring board has **several protruding electrodes** (1) on its surface. An electrode (8) of semiconductor device and the **protruding electrodes** are electrically bonded using an electroconductive glue (6). The semiconductor device (7) is mounted on wiring board and gap between them is filled using a combination of electroconductive glue and sealing **resin** (9) or an anisotropic electrically- conductive sheet.

USE - None given.

JP 11026631 A UPAB: 19990416

AB

AB

ADVANTAGE - Offers reliable semiconductor mounting without requiring severe flat property of wiring board. The possibility of physical destruction by connection is reduced hence the reliability of electric connection can be improved. Stress generated in the semiconductor device or wiring board is dispersed. The dynamic damage to semiconductor device and wiring board is reduced. DESCRIPTION OF DRAWING(S) - The figure shows the mounting method of semiconductor device using electroconductive view and sealing resin. (1) Protruding electrodes; (6) Electroconductive glue; (7) Semiconductor device; (8) Semiconductor device electrode; (9) Sealing resin. Dwg.1/3

```
ΑN
     1999-159570 [14]
                       WPIX Full-text
    N1999-116167
DNN
    Resin sealed package for semiconductor device - includes stud
ΤI
     bump which contacts metal film formed on semiconductor
     device.
DC
    U11
PΑ
    (FUIT) FUJITSU LTD
CYC 1
                                                15
                                                      H01L023-12
     JP 11017054
                    A 19990122 (199914) *
                    B2 20010703 (200139)
                                                15
                                                      H01L023-12
     JP 3181243
     JP 11017054 A JP 1997-168578 19970625; JP 3181243 B2 JP 1997-168578
     19970625
    JP 3181243 B2 Previous Publ. JP 11017054
FDT
PRAI JP 1997-168578
                         19970625
     ICM H01L023-12
```

L41 ANSWER 24 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN

JP 11017054 A UPAB: 19990412

NOVELTY - The semiconductor device (11) is sealed by a resin package (12). A resin protrusion (17) is formed on the mounting side of the resin package. The resin protrusion contacts a metal film (13) formed on the semiconductor device. A wire (18) connects the electrode pad (14) and the metal film. A stud bump (40) is provided in the metal film such that it pierces into the interior of the package.

USE - For semiconductor device.

ICS H01L021-60; H01L023-28; H01L023-50

ADVANTAGE - The peeling of **metal film** from **resin protrusion** is prevented. DESCRIPTION OF DRAWING(S) - The drawing shows the sectional view of the semiconductor device. (11) Semiconductor device; (12) **Resin** package(13) Metal **film**; (14) **Electrode pad**; (17) **Resin protrusion**; (18) Wire; (40) Stud **bump**. Dwg.1/25

```
L41 ANSWER 26 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN
AN
    1994-318665 [40]
                       WPIX Full-text
                       DNC C1994-151778
DNN N1994-261841
     Interconnector for effectively connecting electronic devices and
     circuits vertically through multilayer circuit boards - comprising
     preformed conductive cones which are forced through resin
     supporting member under pressure to make contact with wiring patterns
     formed by etching foil on opposite sides.
DC
     A85 L03 U11 U14 V04
     ARAI, Y; IKEGAYA, F; IMAMURA, E; KOWATARI, S; MORI, T; ODAIRO, H; SASAOKA,
ΙN
     K; WADA, Y; ODAIRA, H
     (TOKE) TOSHIBA KK
PΑ
CYC 8
                   A2 19941019 (199440)* EN
    EP 620701
                                                   H05K003-40
PΙ
        R: DE FR GB
                  A 19941213 (199509)
                                               9 H05K003-40
     JP 06342977
                                                    H05K003-40
                   A3 19950215 (199540)
     EP 620701
                                                  H05K001-00
                                               22
     US 5600103
                  A 19970204 (199711)
                                                     H05K003-40
                  B1 19980708 (199831) EN
     EP 620701
                   A 19981020 (199849)
                                                     H05K003-02
     US 5822850
PRAI JP 1993-90177
                         19930416; JP 1993-131726
                                                        19930602;
     JP 1993-152006
                         19930623; JP 1993-223329
    No-SR.Pub; DE 9102817; US 3488429; US 3835531; US 4991285
REP
     ICM H01R011-01; H05K001-00; H05K001-11; H05K003-02; H05K003-40;
IC
          H05K003-46
     ICS H05K001-18; H05K003-32
           620701 A UPAB: 19941212
AB
       Interconnector (1) comprises synthetic resin supporting member (4) having nearly circular, cone
     shaped conductive lead portions (2') pierced vertically into it at spaced locations. The bottom
     surface of each lead portion is fully exposed on one main surface of the resin supporting member
```

L41 ANSWER 25 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN

having protrusions and coated with insulated resin or impregnated with insulating varnish.

JP 07022252 A JP 1993-189429 19930630

JP 07022252 A UPAB: 19950404

WPIX Full-text

A 19950124 (199513) \*

resin or impregnation process of insulating resin in it.

19930630

H01F027-32

The layer type inductor consists of flat board type coil electric conductors (2). On the surface of the electric conductors, an electric insulation skin layer (3) is formed. The different layers of electric conductor have mutual connections. A protruding line (5) of the secondary side coil (2b), is formed on the electric conductor so that, it does not overlap with the protruding line (4) of the primary side coil (2a). The moulding of the electric conductor is done by insulated

USE/ADVANTAGE - For use in winding wire electric conductor. Guarantees electric insulation breakdown voltage characteristics between coil electric conductors. Enables automatic assembly.

and the top surface of each protrudes from the other surface. Also claimed is a printed wiring board having an insulating synthetic resin supporting member pierced by conductive lead portions at intervals and a metal wiring pattern connected to at least one of the conductive lead portions. Also claimed is a method of fabricating the printed wiring board by superposing a main surface of the synthetic resin sheet on a main surface of a supporting member with conductive bumps at predetermined positions and pressurizing the laminate thus formed so that the bumps pierce

vertically into the resin sheet to form through-type conductive lead portions.

DNC C1995-043736 Layer type inductor - incorporates coil electric conductor

AN

DC

PΑ CYC

PΙ

ADT

IC

AB

1

1995-095274 [13]

(TOHM) TOKIN CORP

DNN N1995-075069

A85 L03 V02

JP 07022252

ICM H01F027-32

ICS H01F027-28

PRAI JP 1993-189429

Dwg.2/5

USE - Interconnector effectively connects electronic devices and forms electronic circuits on printed wiring boards having densely connected lines and components.

ADVANTAGE - The conductive bumps can be precisely and densely formed and located using a printing or plating method and can be reliably connected to an opposed **conductive layer**. Consequently, circuit boards can be fabricated with high efficiency with few rejects. (Reissued from week 9440 to add EPI classifications/ Reprinted in week 9442)

Dwg.1/17

ABEQ US 5600103 A UPAB: 19970313

An inter-connector, comprising: a synthetic **resin** supporting member; and nearly circular cone shaped conductive lead portions pierced vertically into the synthetic **resin** supporting member and spaced apart from each other, where a bottom surface of each of the circular cone shaped conductive lead portions is flatly exposed on one main surface of the synthetic **resin** supporting member and top portions of the circular cone shaped **conductive** lead portions **protrude** from **other** surface of the synthetic **resin** supporting member.

Dwg.1/29

```
L41 ANSWER 27 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN
AN
    1993-243453 [30] WPIX Full-text
DNN N1993-187266
     Flexible circuit wiring board with finger lead conductors - has insulating
     base with conductor pattern covered by protection layer with notches for
     formation of conductors by abrasion while radiating by excimer laser.
DC
     U11
    INABA, M; IWAYAMA, T; MIYAGAWA, A
TN
    (NIMF) NIPPON MEKTRON KK
PA
CYC 3
                                                   H01L021-60
                                                                    <--
                    A1 19930722 (199330) * JA 10
    WO 9314516
PΙ
        W: DE US
     JP 05190755 A 19930730 (199335)
                                                     H01L023-50
                                                5
                                                     H05K003-00
     US 5444188
                    A 19950822 (199539)
                    A 19950829 (199540)
                                                6
                                                     H05K001-02
     US 5446245
     JP 3088175
                    B2 20000918 (200048)
                                                4
                                                     H01L021-60
    WO 9314516 A1 WO 1993-JP28 19930112; JP 05190755 A JP 1992-24469 19920114;
     US 5444188 A WO 1993-JP28 19930112, US 1993-117010 19930908; US 5446245 A
     Div ex US 1993-117010 19930908, US 1994-251388 19940531; JP 3088175 B2 JP
     1992-24469 19920114
FDT US 5444188 A Based on WO 9314516; JP 3088175 B2 Previous Publ. JP 05190755
PRAI JP 1992-24469
                         19920114
REP JP 03096245; JP 61137353
     ICM H01L021-60; H01L023-50; H05K001-02
     ICS H05K003-40
         9314516 A UPAB: 19951019
AΒ
     WO
     The flexible circuit wiring board has circuit wiring conductors (2A), each having a flexible
     insulation resin layer whose width is nearly equal to that of the circuit wiring conductor (2A),
     on a part of at least one side of the conductor (2A), forming a part (6) for reinforcing a
```

formed. A part of the insulation base material (1) is removed at the places where the circuit wiring conductors (2A) are to be formed, by abrasion while projecting an excimer laser beam onto it from the insulating base material (1) side.

ADVANTAGE - Structure is hard to deform even with fine circuit wiring conductors protruded in

On one side of an insulation base material (1) a required circuit wiring conductor pattern (2) is formed. On the top surface of the pattern (2), a surface protection layer (5) is formed in which notch parts (7) are provided at places where the circuit wiring conductors (2A) are to be

ADVANTAGE - Structure is hard to deform even with line circuit willing conductors procluded in form of finger leads.

ADVANTAGE - Structure is hard to deform even with fine circuit wiring conductors protruded in form of finger leads. Dwg.2/4
Dwg.2/4

ABEQ US 5444188 A UPAB: 19951004

terminal.

flexible circuit wiring board having protruding, closely spaced leads, which are intended to be attached to a circuit device, is fabricated by forming a conductor pattern on a first surface of an insulating substrate, adhering a protection layer to the conductor pattern and employing a laser to selectively etch away the substrate.

The etching process leaves a reinforcing coating of the protective layer on the leads at least in the portions thereof which lie at the boundary of the area from which the substrate has been removed.

The method of producing flexible circuit wiring boards involves forming a circuit wiring pattern consisting of number conductors on one surface of an insulating base member. A surface protection layer is adhered to the exposed surface of the circuit wiring pattern, and has at least a first cutaway portion at a location where conductors of the wiring pattern are to be terminated as projecting finger-like leads.

The insulating base member is removed from areas where the leads are to be formed by projecting the beam of an excimer laser onto the base member. The cut-away portion of the surface protection layer is formed by projecting the excimer laser beam onto the exposed surface of the protection layer to remove a portion of the layer.

ADVANTAGE - Increased wiring density.

Dwg.1,2/4

ABEO US 5446245 A UPAB: 19951011

The printed circuit comprises a flexible insulating base member having at least a first edge which at least in part defines a connection region and an aperture in the base member. A pattern of conductors are supported on the base member, at least some of which extend outwardly from the base member beyond the first edge into the connection region.

A flexible protective layer of non-conductive material is formed over the pattern of conductors on the base member, portions of which extend beyond the base member first edge in registration with the outwardly extending conductors to enhance the structural integrity of the conductors in the connection region. The protective layer comprises an insulating film and an adhesive, the adhesive securing the film to the conductors.

```
L41 ANSWER 28 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN
```

AN 1993-122913 [15] WPIX <u>Full-text</u>
DNN N1993-093693 DNC C1993-055043

Forming protruded electrode of semiconductor device by applying 1st and 2nd metal films, then simultaneously depositing metal
coated soft balls and electroplating film.

DC L03 M11

PA (OKID) OKI ELECTRIC IND CO LTD

CYC 1

PI JP 05062981 A 19930312 (199315) \* 7 H01L021-321

ADT JP 05062981 A JP 1991-283378 19911030

PRAI JP 1991-145075 19910618

IC ICM H01L021-321

ICS C23C018-31; C25D005-02; C25D015-02; H01L021-60

AB JP 05062981 A UPAB: 19930924

The formation comprises (a) forming a first metallic film to at least ensure close attaching and preventing metal diffusion, and a second metallic film to improve attachability of electroplating in the post-process and stabilising chemically, on the electrode of the semiconductor device, and (b) forming the **protruded electrode** consisting of one **layer** or arrayed soft balls on the second metallic film by suspending metal coated soft balls in electroplating bath, and depositing the plating metal and the balls together.

Pref. the ball is plastic and coated with Ni, Au, Cu, Co, Sn, Ag, Pd, Pt, Ph and Ru, non-electrolytically.

USE/ADVANTAGE - Used for formation of the **protruded electrode** of the semiconductor device to be used for the chip-on-glass mounting or the chip-on-board mounting. Good connection of the electrode can be obtd. even with small loading. Damage on the device and the electrode pad can be reduced. 1/8

FS CPI

FA AB; GI

```
L41 ANSWER 29 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN
    1992-303901 [37] WPIX Full-text
DNN N1992-232706
                       DNC C1992-135045
    Simply prepared lightweight LC panel having improved contrast - has
TΙ
     insulator protrusions formed on signal lines of array substrate, polymer
    dispersed LC filled in between protrusions and transparent
    electrode layer formed on LC.
    A85 L03 P81 U14
DC
PΑ
     (MATU) MATSUSHITA ELEC IND CO LTD
CYC
    1
                                              10
                                                     G02F001-1333
                   A 19920730 (199237)*
     JP 04208924
PΙ
ADT JP 04208924 A JP 1990-317222 19901120
PRAI JP 1990-317222
                         19901120
    ICM G02F001-1333
TC
     ICS G02F001-335
AB
     JP 04208924 A UPAB: 19931006
     The panel comprises insulator protrudings formed on signal lines of an array substrate, a polymer
     dispersed LC filled in between the protrudings, and an electrode layer of a transparent electric
     conductor formed on LC.
          Pref an optical mask layer is formed on the protrudings; the protrudings are formed on the
     signal line as stripes; and no substrate is placed on the electrode layer. Pref. the protrudings
     are formed on the signal line of the substrate, a resin containing LC is coated on it, a separable
     resin film is laminated on it, the resin is flatted by pressing, the resin is cured, then the film
     is removed.
          USE/ADVANTAGE - The panel is suitable for TV, the method allows production of lightweight and
     high contrast LC panel.
          In an example, LC was prepared from a source drive IC (12), gate drive IC (13), ITO opposed
     electrode (14), SiNx insulating protection film (15), wiring (19) for impressing required
     potential to (14), conductor paste (17) for connecting (14) and (19), LC polymer (18, 21) (e.g.
     nematic LC), source signal line (22). Picture element electrode (23) connected to TFT and
     insulator protrudings (25) formed on (22) were formed on array substrate (11) by conventional
     method using photolithography etc. (Dwg.la,b/
     1a,b/9
L41 ANSWER 30 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN
AN
     1992-246802 [30] WPIX Full-text
     Aperture formation method on metal protrusion
ΤI
     substrate - forming conductive film on insulated
     substrate, insulation film on conductive film
     and mask for photoresist etching on insulation film NoAbstract.
DC
     1111
     (MATU) MATSUSHITA ELEC IND CO LTD
PΑ
                                                5
                                                     H01L021-60
     JP 04167536 A 19920615 (199230)*
                                                                    <--
ΡI
ADT JP 04167536 A JP 1990-295772 19901031
                        19901031
PRAI JP 1990-295772
    ICM H01L021-60
IC
L41 ANSWER 31 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN
     1992-220693 [27] WPIX Full-text
AN
     Substrate with metal protrusion for mounting IC - has
TΙ
     conductive film, rectangular or circular opening, and
     metal protrusion, thus reduces damage to chip
     NoAbstract.
     (MATU) MATSUSHITA ELEC IND CO LTD
PA
                                           5 H01L021-321
    JP 04082226 A 19920316 (199227)*
PΙ
                         19900724
PRAI JP 1990-196635
IC ICM H01L021-321
     ICS H01L021-60
```

```
L41 ANSWER 32 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN
                       WPIX Full-text
     1992-076005 [10]
ΑN
     Electrical connecting member for fixing circuit parts on substrate -
TΙ
     comprises holder of insulative material in which are embedded
     conductive members, with ends protruding and covered
     with conductive adhesive layer of pulverised metal or
     metallised ceramic powder.
DC.
     U11 U14 V04
     KADOKURA, S; YOSHIZAWA, T
IN
     (CANO) CANON KK
PΑ
CYC 2
                    A 19920123 (199210)*
PΙ
     JP 04019972
                                                 6
                   A 19921229 (199303)B
                                               16
                                                      H01R013-00
     US 5174766
     JP 04019972 A JP 1990-121496 19900511; US 5174766 A Cont of US 1991-697776
ADT
     19910509, US 1991-810444 19911219
     US 5174766 A JP 04019971, JP 04019972
FDT
                          19900511; JP 1990-121494
                                                         19900511;
PRAI JP 1990-121496
     JP 1990-121495
                          19900511
     ICM H01R013-00
     ICS H01L021-60; H01R004-04; H01R009-09; H01R011-01;
          H05K001-18; H05K003-36
     JP 04019972 A UPAB: 19990922
AB
      The electrical connecting member includes a holder made of electrically insulative material, and a
      number of conductive members electrically insulated from each other and embedded in the holder and
      having ends exposed from the holder. A conductive adhesive layer eutectoidally formed by
      electrophoresis from an adhesive resin solution including one or both of pulverised metal powder
      and metallised ceramic powder is disposed on the end of each conductive member exposed from one
      holder surface.
          The conductive adhesive layers and the other ends of the conductive members exposed from the
      other holder surface are flush with or protruded from the surfaces of the holder. Wirings in or on
      the holder surface connect some conductive members together.
          ADVANTAGE - Easily interconnects circuit parts with low temps. by using connecting member
      with conductive adhesive layer on connecting portions. (First major country equivalent to
      JP4019970/1/2)
FS
     AB; GI
     EPI: U11-D03A9; U11-E01X; U14-H03A2; V04-A09; V04-M05; V04-Q02B; V04-A06;
MC
          V04-A07; V04-B01
```

```
L41 ANSWER 33 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN
    1992-076004 [10]
                       WPIX Full-text
AN
    Electrical connecting member for fixing circuit parts on substrate -
ΤI
     comprises holder of insulative material in which are embedded
     conductive members, with ends protruding and covered
     with conductive adhesive layer of pulverised metal or
     metallised ceramic powder.
     U11 U14 V04
DC
    KADOKURA, S; YOSHIZAWA, T
IN
     (CANO) CANON KK
PA
CYC 2
                    A 19920123 (199210)* 6
A 19921229 (199303)B 16
PΙ
     JP 04019971
                                                      H01R013-00
     US 5174766
     JP 04019971 A JP 1990-121495 19900511; US 5174766 A Cont of US 1991-697776
ADT
     19910509, US 1991-810444 19911219
FDT US 5174766 A JP 04019971, JP 04019972
PRAI JP 1990-121495
                          19900511; JP 1990-121494
                                                        19900511;
                          19900511
     JP 1990-121496
IC
     ICM H01R013-00
     ICS H01L021-60; H01R004-04; H01R009-09; H01R011-01;
          H05K001-18; H05K003-36
     JP 04019971 A UPAB: 19990922
AB
     The electrical connecting member includes a holder made of electrically insulative material, and a
```

The electrical connecting member includes a holder made of electrically insulative material, and a number of conductive members electrically insulated from each other and embedded in the holder and having ends exposed from the holder. A conductive adhesive layer eutectoidally formed by electrophoresis from an adhesive resin solution including one or both of pulverised metal powder and metallised ceramic powder is disposed on the end of each conductive member exposed from one holder surface.

The conductive adhesive layers and the other ends of the conductive members exposed from the other holder surface are flush with or protruded from the surfaces of the holder. Wirings in or on the holder surface connect some conductive members together.

ADVANTAGE - Easily interconnects circuit parts with low temps. by using connecting member with conductive adhesive layer on connecting portions. (First major country equivalent to JP4019970/1/2)

```
L41 ANSWER 34 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN
    1992-076003 [10]
                      WPIX Full-text
AN
     Electrical connecting member for fixing circuit parts on substrate -
     comprises holder of insulative material in which are embedded
     conductive members, with ends protruding and covered
     with conductive adhesive layer of pulverised metal or
     metallised ceramic powder.
DC.
     U11 U14 V04
     KADOKURA, S; YOSHIZAWA, T
IN
     (CANO) CANON KK
PA
CYC
     JP 04019970
                    A 19920123 (199210)*
PΙ
                                                6
                   A 19921229 (199303)B
                                               16
                                                     H01R013-00
     US 5174766
     JP 04019970 A JP 1990-121494 19900511; US 5174766 A Cont of US 1991-697776
ADT
     19910509, US 1991-810444 19911219
    US 5174766 A JP 04019971, JP 04019972
FDT
                         19900511; JP 1990-121495
                                                        19900511;
PRAI JP 1990-121494
     JP 1990-121496
                         19900511
     ICM H01R013-00
     ICS H01L021-60; H01R004-04; H01R009-09; H01R011-01;
         H05K001-18; H05K003-36
     JP 04019970 A UPAB: 19990922
AB
```

The electrical connecting member includes a holder made of electrically insulative material, and a number of conductive members electrically insulated from each other and embedded in the holder and having ends exposed from the holder. A **conductive** adhesive **layer** eutectoidally formed by electrophoresis from an adhesive **resin** solution including one or both of pulverised metal powder and metallised ceramic powder is disposed on the end of each conductive member exposed from one holder surface.

The conductive adhesive layers and the other ends of the conductive members exposed from the other holder surface are flush with or protruded from the surfaces of the holder. Wirings in or on the holder surface connect some conductive members together.

ADVANTAGE - Easily interconnects circuit parts with low temps. by using connecting member with conductive adhesive layer on connecting portions. (First major country equivalent to JP4019970/1/2)

```
L41 ANSWER 35 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN
    1987-343440 [49]
                       WPIX Full-text
DNN N1987-257151
    Ultrasonic transducer for on-line applications - has nose piece contacting
ΤI
     sheet material and attached to parallel piped-shaped piezoelectric
    S02 V06
DC
    BOKOWSKI, G A; VAHEY, D W
IN
     (ACCU-N) ACCU RAY CORP; (ACCU-N) ACCURAY CORP; (PROC-N) PROCESS AUTOM
PA
CYC
ΡI
    EP 248512
                    A 19871209 (198749) * EN
                                                17
        R: DE FR GB IT SE
                 A 19871215 (198806)
                                                 7
     US 4713572
                    C 19910820 (199138)
     CA 1287913
                    B1 19920819 (199234) EN
                                                     G01H011-08
     EP 248512
        R: DE FR GB IT SE
     DE 3781207
                    G 19920924 (199240)
                                                     G01H011-08
    EP 248512 A EP 1987-303010 19870407; US 4713572 A US 1986-872049 19860606;
     EP 248512 B1 EP 1987-303010 19870407; DE 3781207 G DE 1987-3781207
     19870407, EP 1987-303010 19870407
FDT DE 3781207 G Based on EP 248512
PRAI US 1986-872049
                         19860606
REP A3...8914; No-SR.Pub; US 3935484; US 3950660; US 4291577; US 4562372
     ICM G01H011-08
IC
     ICS H01L041-08; H04R017-00
     EΡ
           248512 A UPAB: 19930922
AB
     The piezo-electric element (4), e.g. of a lead zirconate-lead titanate ceramic, has nominal
     dimensions of length (6) one inch, width (8) one fourth of an inch and a thickness (10) of one
     eighth of an inch. An electrode film is deposited on one surface (12) and an opposite main
     surface. A nose-piece is rigidly attached to the element by an adhesive, pref. a conductive
     epoxy.
          Electrical contact between the electrode film and the external electrical communication
     system can be by a protruding glob of conductive epoxy. The sheet material is brought into
     contact with the transducer at the contacting surface of the nose-piece.
          USE/ADVANTAGE - Withstands rigours of on-line environment while avoiding damage to sheet
     material due to movement. Detects ultrasonic waves of predominantly one propagation mode for
     measuring physical parameter of sheet material.
     1/5
          3781207 G UPAB: 19930922
ABEQ DE
     The piezo-electric element (4), e.g. of a lead zirconate-lead titanate
     ceramic, has nominal dimensions of length (6) one inch, width (8) one
     fourth of an inch and a thickness (10) of one eighth of an inch. An
     electrode film is deposited on one surface (12) and an opposite main
     surface. A nose-piece is rigidly attached to the element by an adhesive,
     pref. a conductive epoxy.
          Electrical contact between the electrode film and the external
     electrical communication system can be by a protruding
     glob of conductive epoxy. The sheet material is brought into
     contact with the transducer at the contacting surface of the nose-piece.
          USE/ADVANTAGE - Withstands rigours of on-line environment while
     avoiding damage to sheet material due to movement. Detects ultrasonic
     waves of predominantly one propagation mode for measuring physical
     parameter of sheet material.
           248512 B UPAB: 19930922
ABEO EP
     A transducer for transmitting ultrasound into a medium through which
     ultrasound is propagated or for receiving ultrasound therefrom, and
     comprising a piezoelectric element having opposite parallel faces one of
     which, in use, is presented toward said medium, and upon both of which
     faces respective electrode films are deposited, with a protective covering
     over the electrode film on said face that, in use, is presented toward
     said medium, characterised in that the piezoelectric element (4) has the
     shape of a parallelepiped whereof the length (6) is greater than the width
     (8) and the width is greater than the thickness (10), and the respective
     electrode films are deposited on opposite surfaces (12, 14) whose
     dimensions are the length and width of the element, the direction of
```

vibration of the element when a voltage is applied across said electrode

lying along the longitudinal axis (x) of the element, and the protective covering comprises at least a nosepiece (16) having two opposite surfaces one of which (18) constitutes a joining surface that is rigidly affixed to one of said electrode surfaces of the piezoelectric element, and the other (20) being contacting surface for contact with said medium (22). (Dwg.1,2,4 1,2,4/5

ABEO US 4713572 A UPAB: 19930922

The transducer comprises a piezoelectric element having the shape of a parallelepiped, and a metallic nosepiece rigidly attached to a surface of the element and adapted for contact with sheet material through which ultrasound is propagated. The contacting surface is confined to a location that is near a longitudinal extreme of the transducer.

A portion of the nosepiece is rounded or bevelled with the contacting surface being rectangular or spherically convex.

ADVANTAGE - Provides efficient transmission of ultrasound and reduces risk of damage to moving sheet material.

```
L41 ANSWER 36 OF 36 WPIX COPYRIGHT THOMSON DERWENT on STN
AN 1986-228593 [35] WPIX Full-text
TI Mfg. substrate for forming protruding metal - forming
    conductive film, insulating film and resist
    pattern, first two having sequential holes NoAbstract DWg 2/2.
    U11
DC
    (MATU) MATSUSHITA ELEC IND CO LTD
PΑ
CYC 1
PI JP 61158166 A 19860717 (198635) *
ADT JP 61158166 A JP 1984-275494 19841229
PRAI JP 1984-275494 19841229
IC
    H01L023-48
FS
    EPI
FA
    NOAB
MC EPI: U11-D03A; U11-E01
```

#### L49 ANSWER 3 OF 10 EUROPATFULL COPYRIGHT WILA on STN

PATENT APPLICATION - PATENTANMELDUNG - DEMANDE DE BREVET

AN 1011141 EUROPATFULL ED 20000702 EW 200025 FS OS Full-text
TIEN Semiconductor device and process for producing it.

IN Kobayashi, Syoichi, Shinko Elec. Ind. Co. Ltd., Aza Shariden Oaza Kuri,
PA SHINKO ELECTRIC INDUSTRIES CO. LTD., 711, Aza Shariden, Oaza Kurita,
PI PI PI D111141 A2 20000621

PI - EP 1011141 A2 20000621 PRAI JP 1998-359229 19981217

electrodes (32). <image>

PRAI JP 1998-359229 19981217

A semiconductor device has excellent bonding strength of bumps (38) with their respective protruded electrodes (32) and has high reliability. A wiring pattern (28) to be connected to an electrode (22) of a semiconductor chip (20) is formed on an insulating film (23) formed on the semiconductor chip (20) in which the electrode (20) is formed. Protruded electrodes (32) are formed on the wiring pattern (28). The wiring pattern (28) is covered with a protective film (36), and a bump (38) for external connection is formed on the end portion of each of the protruded electrodes (32) exposed from the protective film (36). The bump (38) is formed in such a manner that the bump is bonded to at least the entire end face of each of the protruded

#### DETDEN

CLMEN.

. . electrode of a semiconductor chip is formed on an insulating film formed on the semiconductor chip surface on which the **electrode** is formed, **protruded electrodes** are formed on the wiring pattern, the wiring pattern is covered with a protective film, and a bump for external connection is formed on the end portion of each of the **protruded electrodes** exposed from the protective film,

the bump being formed by bonding the bump to the at least entire end face of each of the **protruded electrodes**.

- 2. . . device according to claim 1, wherein a barrier plated layer is formed on the end face of each of the **protruded electrodes**, and the **bump** is formed in such a manner that the bump is bonded to the entire barrier plated layer.
- 3. . . in such a manner that the top surface of the protective film is lower than the position at which the bump is bonded to the protruded electrode.
- 4. . . . according to claim 1 or 2, wherein an oxide film is formed on the peripheral surface of each of the **protruded** electrodes, and there is a gap between the protective film and the peripheral surface of each of the **protruded** electrodes.
- 5. . . in such a manner that the top surface of the protective film is higher than the position at which the **bump** is bonded to the **protruded electrode**, and that part of the peripheral surface of the bump is contacted with the protective film.

6. . . electrode of a semiconductor chip is formed on an insulating film formed on the semiconductor chip surface on which the electrode is formed, protruded electrodes

are formed on the wiring pattern, the wiring pattern is covered with a protective film, and a bump for external connection is formed on the end portion of each of the **protruded electrodes** exposed

from the protective film, the process comprising the steps of:

covering the wiring pattern formed on the insulating. . . resist layer to expose part of the wiring pattern;

plating the wiring pattern within the holes to form the protruded electrodes;

removing the resist layer;

effecting sealing by supplying a **resin** to the wiring pattern to form a **resin** layer having a top surface lower than that of the **protruded electrodes**, thereby forming a protective film; and

forming the bump on each of the protruded

#### PATENT APPLICATION - PATENTANMELDUNG - DEMANDE DE BREVET

AN 987749 EUROPATFULL ED 20000402 EW 200012 FS OS Full-text

TIEN Semiconductor device, electrode structure therefore, and production thereof.

TIDE Halbleitervorrichtung, Elektrodenstruktur fuer diesselbe und dessen Herstellungsverfahren.

TIFR Dispositif semiconducteur, sa structure d'electrode et son procede de fabrication.

IN Kirloskar, Mohan, c/o Shinko Electric America Inc., 3211 Scott Blvd, Suite 101, Santa Clara, California 95054, US; Horiuchi, Michio, c/o Shinko Electric Ind. Co.Ltd., 711 Aza Shariden, Oaza Kurita, Nagano-shi, Nagano 380-0921, JP; Takeuchi, Yukiharu, c/o Shinko Electric Ind.Co.Ltd, 711 Aza Shariden, Oaza Kurita, Nagano-shi, Nagano 380-0921, JP

SHINKO ELECTRIC INDUSTRIES CO. LTD., 711, Aza Shariden, Oaza Kurita, Nagano-shi, Nagano 380-0921, JP

PAN 1161831

PΑ

AG Rackham, Stephen Neil, GILL JENNINGS & EVERY, Broadgate House, 7 Eldon Street, London EC2M 7LH, GB

 PI
 EP
 987749
 A2
 20000322

 OD
 20000322

 AI
 EP
 1999-306984
 19990902

 PRAI
 JP
 1998-248146
 19980902

A semiconductor device comprising a semiconductor chip (10) having an electrode terminal carrying surface and electrode terminals (12) formed on, and carried by, the electrode terminal carrying surface. Leads (30) extend substantially parallel to the electrode terminal carrying surface, each lead (30) having at least one curved portion, a first bump (40) and a second bump (28) which are formed on opposite ends respectively of each of the leads (30) and protrude from the ends in opposite directions toward and away from, respectively, the electrode terminal carrying surface. The electrode terminals (12) of the semiconductor chip (10) are each bonded to a top of the first bump (40) of the lead (30) to support the leads (30) at a distance from the electrode terminal carrying surface of the semiconductor chip (10). <image>

DETDEN. . . semiconductor wafer in which high precise positioning is necessary. A semiconductor water may not have a terminal on a passivation film and the electrode connection terminal 40 may be directly bonded to an electrode terminal of the chip precursors of the wafer.

CLMEN. . . extending substantially parallel to said one side of the card base and having at least one curved portion, said probe **contact** and said bond terminal **protruding** from one and the other ends of the lead, respectively, in opposite directions toward and away from said one side. . .

6. A method for forming a protruding electrode,

said step of forming said first film is conducted

according to claim 2, wherein:

by a printing process using a mask.

```
ANSWER 6 OF 10 EUROPATFULL COPYRIGHT
L49
PATENT APPLICATION - PATENTANMELDUNG - DEMANDE DE BREVET
       742643 EUROPATFULL ED 19970307 EW 199646 FS OS Full-text
      An acoustic surface-wave device and its manufacturing method.
TIEN
       Onishi, Keiji, 2-2-10, Hitotsuya, Settu-shi, Osaka 566, JP;
      MATSUSHITA ELECTRIC INDUSTRIAL CO., LTD., 1006, Oaza Kadoma, Kadoma-shi,
PΑ
                         A1 19961113
       EP 742643
ΡI
                              19950508
PRAI
       JP 1995-109649
       The objects of this invention are to offer a compact, low height, low cost, and high reliability
ABEN
       acoustic surface-wave device, and its manufacturing method. In order to accomplish the objects
       of the invention, the invented acoustic surface-wave device is constituted of a substrate (101),
       comb-electrode (102) disposed on the main surface of said substrate plural electrode pads (103)
       disposed around said comb-electrode, protecting means (112) covering said comb-electrode through
       a closed space produced by combining said comb-electrode and said plural electrode pads with
       said substrate by using substantially covalent bonding force acted between, conductive bumps
        (104) formed on said plural electrode bumps, a conductive adhesive layer (105) disposed at least
       on the top of said conductive bumps, and a package (107) adhered on said conductive bumps by
       means of said conductive adhesive, and insulation adhesive filled into said package contacting
       with said conductive adhesive, said conductive bumps, and said protective means. <image>
CLMEN. . . between said comb-electrode and said plural electrode pads,
       conductive bumps formed on the tops of said plural electrode pads, a
       conductive adhesive layer disposed at least on the
       tops of said conductive bumps, a package adhered on said conductive bums
       by means of. . .
       1. . . a protection means (112);
          conductive bumps (104) formed on the tops of said plural electrode
       pads (103);
           a conductive adhesive layer (105) disposed at
       least on the tops of said conductive bumps (104);
           a package (107) adhered on said conductive. . . height of a base
       of each conductive bump is higher than the height of the protective
       mans, where each conductive bump has a double
       protrusion structure consisting of a top and a base.
       6. An acoustic surface-wave device according to Claim 1; wherein said
       conductive bump consists of a base bonded to said {\bf electrode}
       pad and a protrusion formed on said base where said the height
       of said base is lower than the height of said protecting means..
       6. . . acoustic surface-wave device according to claim 1, wherein
       said conductive bump (104) consists of a base (104b) bonded to said
       electrode pad (103) and a protrusion (104a) formed on
       said base (104b), wherein the height of said base (104b) is higher than
       the height of said. .
       7. . . comprising; a comb-electrode formed on the main surface of
       said substrate, plural electrode pads disposed on the peripheral of said
       comb-electrode, an insulating layer formed to
       surround said comb-electrode at an area between said comb-electrode and
       said plural electrode pads, a protection means covering. . . said
       comb-electrode and said plural electrode pads, a conductive bumps formed
       on the tops of said plural electrode pads, a conductive
       adhesive layer disposed at least on the tops of said
       conductive bumps, a package adhered on said conductive bumps by means
       of. . .
       10. . . (112);
           a process to form conductive bumps (104) on said plural electrode
       pads (103);
           a process to form conductive adhesive layer
       (105) at least on the tops of said conductive bumps (104);
           a process to adhere said conductive bumps (104). . . height of a
       base of each conductive bump is higher than the height of the protective
       mans, where each conductive bump has a double
       protrusion structure consisting of a top and a base,
       14. An acoustic surface-wave device according to Claim 7; wherein said conductive bump consists
of a base bonded to said electrode pad and a protrusion formed on said base, and the height of said
base is lower than the height of protecting means.
     15. . . said plural electrode pads, a process to form conductive
```

bupms on said plural electrode pads, a process to form a **conductive** adhesive **layer** at least on the tops of said conductive bumps, a process to adhere said conductive bumps on to said electrode.

#### L49 ANSWER 8 OF 10 EUROPATFULL COPYRIGHT WILA on STN

PATENT APPLICATION - PATENTANMELDUNG - DEMANDE DE BREVET

AN 316912 EUROPATFULL ED 20000924 EW 198921 FS OS STA B <u>Full-text</u>

TIEN A bump electrode structure of a semiconductor device and a method for forming the same.

IN Wakabayashi, Takeshi Pat. Dpt. Dev. Div Hamura R&D, Center Casio

 PI
 EP
 316912
 A2
 19890524

 PRAI
 JP
 1987-289257
 19871118

 JP
 1987-294133
 19871124

 JP
 1988-105302
 19880427

ABEN A bump electrode structure of a semiconductor device comprises an electrode pad (13) formed of an alu.shy. minum alloy, an insulating oxide layer (14) covering only the peripheral edge portion of the electrode pad (13), an under-bump layer (15) formed of an alloy of titanium and tungsten, and a bump electrode (16) formed of gold. The titanium-tungsten alloy functions both as a barrier metal and as a bonding metal. The bump electrode (16) rises substantially straight from the bonding surface of the under-bump layer (15), and its top portion has an area only substantially equal to that of the electrode pad (13). Fine V-shaped grooves (17) are formed on the top surface of the bump electrode (16) by anisotropic etching. Thus, the semiconductor device with fine electrode pad pitches is provided with a high-.shy. reliability bump electrode structure which ensures suf.shy. ficient bonding strength between internal and external electrodes.

DETDEN. . . 5a is formed on bonding metal layer 4b. Using bump electrode 5 as a mask, thereafter, that portion of under-bump layer 4 outside electrode 5 is removed by etching, as mentioned before. Usually, isotropic wet etching is used for this purpose. In . . . edge portion of the under-bump layer being situated between the respective peripheral edge portions of the opening of the insulating layer and the electrode pad; and a protu.shy. berant bump electrode bonded to the under-bump layer and raised from the peripheral edge portion of. . . Fig. . . inter.shy. mediate junction layer 15 is situated between the outer end of electrode pad 13 and opening 14a of insulating layer 14. Bump electrode 16 of gold is projectingly formed on layer 15. Electrode 16, which is composed of thin gold layer 16a and gold bump 16b, has an overall thickness of about 10. . .

CLMEN. . . being situated between the respec.shy. tive peripheral edge portions of the opening (14a) of the insulating layer (14) and the electrode (13); and

a protuberant bump electrode (16)

bonded to the under-bump (15) and raised from the peripheral edge portion of the under-bump layer (15).

5. 5. A method for forming a bump electrode of a semiconductor device so that the **bump electrode** (16) **protrudes** from the upper surface of an electrode pad (13) whose central portion of is exposed through an opening (14a) of.